

**2024 SOURCE WORKSHOP
OCTOBER 19- 23, 2024
AMSTERDAM, THE NETHERLANDS**



Call for Papers

This leading annual workshop focuses on the latest scientific and technical developments related to extreme ultraviolet (EUV) and soft X-ray sources. The workshop will provide a forum for researchers and end-users in the EUV and Soft X-ray light sources areas to present their work and discuss a wide range of potential applications. We will focus on the generation of photons in this wavelength region, using laser-produced plasma (LPP), discharge-produced plasma (DPP), high-harmonic generation (HHG), free electron lasers (FEL), synchrotrons and innovative concepts. We also welcome papers describing applications of these sources in EUV lithography, and its extension, for scanner and metrology applications, microscopy, analytical instrumentation and for supporting scientific research in material and biological sciences. In addition to experimental studies, we encourage submission of theoretical and modeling papers. This year, once again, the agenda will also include the Code Comparison session for LPP modeling, and the host program showcase sessions.

Abstracts of 200 words or less should be sent to info@euvlitho.com by August 16, 2024. Student papers are highly encouraged. Please, indicate whether an oral or poster presentation is preferred and include each author's full name, e-mail address, affiliation, and mailing address. Please, also include a brief biography and photograph of the presenting author, for inclusion in the abstract book. The workshop proceedings will be published online and made available to all attendees at no cost. The proceedings of the previous workshop are available online at www.euvlitho.com.

For any questions about the workshop please contact us at Info@euvlitho.com. For an opportunity to sponsor the workshop, please contact Belén at belen.sanchez@euvlitho.com.

Abstract Due Date: August 16, 2024

Submit abstract to
info@euvlitho.com

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Venue

Amsterdam, The Netherlands

Registration Information

Coming soon at
www.euvlitho.com

Organized by

